



ITW/AF

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:	Wang Yueh et al.	§	Art Unit:	1752
Serial No.:	10/762,031	§	Examiner:	John S.Y. Chu
Filed:	January 21, 2004	§	Docket:	ITL.1074US P18216
For:	One Component EUV Photoresist	§	Assignee:	Intel Corporation

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY TO FINAL REJECTION**

Sir:

In response to the final rejection mailed August 9, 2005, reconsideration is respectfully requested in view of the following remarks.

Date of Deposit: August 24, 2005

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

*Cynthia L. Hayden*  
Cynthia L. Hayden